

China

CMC

COA

Hcl

Cylinder/Tank

-85.1 °C 36.46

-114.2 ºC

44L, 82.5L

44L, 82.5L

28061000

231-595-7

2000 Tons/Year 7647-01-0

Industrial Pure Air

Industrial Grade

China

HCI

15MPa/20MPa

Anhydrous Hydrogen Chlorde

## Cylinder Gas 99.9% Purity Electronic Gas Anhydrous Hydrogen Chloride

### **Basic Information**

- Place of Origin:
- Brand Name:
- Certification:
- Model Number:
- Minimum Order Quantity: 1kg
- Price: US \$ 9.5/kg
- Packaging Details:
- Delivery Time: 15 days
- Payment Terms: L/C, T/T
- Supply Ability: 20000 Tons/Year



## Product Specification

- Product Name:
- Boiling Point:
- Molecular Weight:
- Melting Point:
- Cylinder Pressure:
- Transport Package:
- Specification:
- Origin:
- HS Code:
- Supply Ability:
- CAS No.:
- Formula:
- EINECS:
- Constituent:
- Grade Standard:



## More Images



Our Product Introduction

#### **Product Description**

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Anhydrous hydrogen chloride (HCl) refers to hydrogen chloride gas that is free of water. It is an anhydrous form of hydrochloric acid, meaning it does not contain any water molecules. Here are some key points about anhydrous hydrogen chloride:

Composition: Anhydrous hydrogen chloride is composed of hydrogen (H) and chlorine (Cl) atoms. It exists as a gas at room temperature and pressure and is typically stored and handled in pressurized cylinders.

Production: Anhydrous hydrogen chloride can be produced by removing water from hydrochloric acid. This can be achieved through various methods, such as using drying agents or distillation techniques to separate the water from the acid.

Properties: Anhydrous hydrogen chloride is a colorless gas with a strong, pungent odor. It is highly soluble in water and readily forms hydrochloric acid when exposed to moisture. The gas is denser than air and can form dense, white fumes in the presence of humidity.

Uses: Anhydrous hydrogen chloride has several applications in various industries:

Chemical Synthesis: It is used as a reactant or catalyst in chemical synthesis reactions, such as the production of organic compounds, dyes, and pharmaceuticals.

Semiconductor Industry: Anhydrous hydrogen chloride is used in the semiconductor industry for etching and cleaning silicon wafers during the manufacturing of microchips and electronic devices.

Metal Processing: It is utilized for metal surface treatment, including pickling and cleaning of metals to remove oxides, scales, and impurities. Laboratory Applications: Anhydrous hydrogen chloride is used in laboratories for various purposes, such as pH adjustment, synthesis, and chemical reactions.

Safety Considerations: Anhydrous hydrogen chloride is highly corrosive and toxic. It can cause severe burns to the skin, eyes, and respiratory system upon contact or inhalation. The gas is also an irritant to the mucous membranes. Proper safety precautions, including the use of appropriate protective equipment, ventilation, and safe handling procedures, should be followed when working with anhydrous hydrogen chloride. Due to its hazardous nature, anhydrous hydrogen chloride should be handled with extreme caution, and its use and storage must comply with strict safety protocols and regulations.

#### Specification:

Specification	Company Standard
HCL	≥ 99.9%
CO2	≤ 400 ppm
CO	≤ 60 ppm
N2	≤ 450 ppm
O2+AR	≤ 30 ppm
THC (as CH4)	≤ 5 ppm
Moisture	≤ 5 ppm

# PRODUCT DETAILS







Company Profile



Shanghai Kemike Chemical Co., Ltd is staffed by trained personnel, combine many years experience in Gas industry .We supply cylinder gas, electronic gas, etc., and the gas holder, panel, valves and fittings and other equipment, parts and engineering services to our customers in China and worldwide; The products are involved in various industrial fields, such as semiconductor chip, solar cell, LED, TFT-LCD, optical fiber, glass, laser, medicine, etc., Our mission is to partner with our global customers to provide support, solutions and quality products that are innovative, reliable, and safe. Our products mainly include: H2, O2, N2, Ar, CO2, propane, acetylene, helium, laser mixed gas, SiH4, Sih2cl2, SiHCL3, SiCL4, NH3, CF4, NF3, SF6, HCL, N2O, doping mixed gas (TMB, PH3, B2H6) and other electronic gases.

SiCl4	NH3	NH3	CH3F SiH4 Kr H2S WF6 F6+Cl2
4MS	C3F8	C3F8	TEOS CH4 PH3 SF6 C2 HCI+Ne
CF4	C4F8	SiH2	TMB+H2
SiF4	C3H8	CI2	He +As
BBr3	C3H6	DCE	Ge+Se
POCI3	N2	SO2	D+B
BCI3	D2	CO2	CO+NO
SiHCI3	CH2F2	HF	AsH3 C2H4 C2H2 HBr COS Ar+O2
TMAI	DMZn	DEZn	GeH4 C2H6 B2H6 H2Se GeCl4 Xe+NO

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